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IN THE CLAIMS

Please cancel Claims 2, 9, and 14-17.

Please amend the claims as follows:

- a5*
1. (Amended) A method comprising:
over an area of a substrate, forming a plurality of three dimensional first structures;
following forming the first structures, conformally introducing a sacrificial material over the area of the substrate;
introducing a second structural material over the sacrificial material;
exposing a portion of the sacrificial material; and
removing the sacrificial material.
- a6*
3. (Amended) The method of claim 1, wherein exposing a portion of the sacrificial material comprises removing a portion of the second structural material.
- a7*
8. (Amended) A method comprising:
over an area of a surface of a substrate, lithographically patterning a plurality of first structures, the plurality of first structures having a first dimension about the surface of the substrate and a second different dimension;
following forming the first structures, conformally introducing a sacrificial material layer over the area of the substrate;
patterning the sacrificial material;
forming second structures over the sacrificial material; and
removing the sacrificial material.
- a8*
11. (Amended) The method of claim 10, wherein exposing a portion of the sacrificial material comprises removing a portion of the second structural material.